


Search Notes 	Application/Control No. 10710698	Applicant(s)/Patent Under Reexamination CHEN ET AL.
	Examiner Kourtney R Salzman	Art Unit 4128

SEARCHED			
Class	Subclass	Date	Examiner
204	192 and 192.12; 298, 298.16	11/29/2007	krs

SEARCH NOTES		
Search Notes	Date	Examiner
Inventor Search in PALM	11/29/2007	krs
Assignee Search in PALM	11/29/2007	krs
Keyword Searching: axial\$3, magnet\$4, rotating, magnetron, method, backplate, degree, symmetr\$3, target in EAST	11/29/2007	krs
Assignee Search for Applied Materials, Inc. patents in EAST	11/29/2007	krs
Updated Searches in EAST	6/23/2008	krs
Search PAJ for magnetron sputtering and polarity	6/23/2008	krs

INTERFERENCE SEARCH			
Class	Subclass	Date	Examiner